



PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Toshiro HAYAKAWA, et al.

Appln. No.: 09/315,068

Confirmation No.: Not Assigned

Group Art Unit: 2881

Filed: May 20, 1999

Examiner: Jeffrey N. Zahn

For: SEMICONDUCTOR LASER AND METHOD OF MANUFACTURING THE SAME

RESPONSE TO RESTRICTION REQUIREMENT

Commissioner for Patents  
Washington, D.C. 20231

Sir:

In response to the Restriction Requirement dated July 31, 2001, Applicant hereby elects the claims of Group I, including claims 1-2 and 5-6. This election is made without traverse.

Timely and favorable consideration on the merits is respectfully requested.

Respectfully submitted,

  
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Date: August 20, 2001

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